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Practitioner's Docket No.: KSM-0226

PATENT APPLICATION

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:  
Masayoshi ICHIKI, et al.

Application No.: 10/509,160

Confirmation No.: 5098

Filed: September 28, 2004

Art Unit: 1754

For: HIGH TEMPERATURE DENITRATION  
CATALYSTS AND PROCESSES FOR PREPARING  
SAME

Examiner: Not Yet Assigned

Attention: Office of Initial Patent Examination's  
Customer Service Center

VIA FACSIMILE: 703-746-9195

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

## REQUEST FOR CORRECTED FILING RECEIPT

- Attached is a copy of the official filing receipt received from the PTO in the above application for which issuance of a corrected filing receipt is respectfully requested.
- There is an error with respect to the following, which is incorrectly entered.

**Error in****Correct data**

1. Title  
1. High temperature denitration catalysts and processes for preparing same
3. The correction is due to an error by the USPTO. If any fee is due, please charge Deposit Account No. 18-0013.

Dated: April 29, 2005

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## UNITED STATES PATENT AND TRADEMARK OFFICE

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APPL NO.	FILING OR 371 (c) DATE	ART UNIT	FIL FEE REC'D	ATTY.DOCKET NO	DRAWINGS	TOT CLMS	IND CLMS
10/509,160	09/28/2004	1754	1512	KSM-0226	5	18	4

23353  
 RADER FISHMAN & GRAUER PLLC  
 LION BUILDING  
 1233 20TH STREET N.W., SUITE 501  
 WASHINGTON, DC 20036

CONFIRMATION NO. 5098

## FILING RECEIPT



\*OC000000015705265\*

Date Mailed: 04/11/2005

Receipt is acknowledged of this regular Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please mail to the Commissioner for Patents P.O. Box 1450 Alexandria Va 22313-1450. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).

## Applicant(s)

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## Assignment For Published Patent Application

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Power of Attorney: The patent practitioners associated with Customer Number 23353.

## Domestic Priority data as claimed by applicant

This application is a 371 of PCT/JP03/03783 03/27/2003

## Foreign Applications

JAPAN 2002-090505 03/28/2002  
 JAPAN 2002-136522 05/13/2002

Projected Publication Date: 07/21/2005

Non-Publication Request: No

Early Publication Request: No

Title

denitration

processes for Preparation

High temperature denitration catalyst and method for preparation thereof

same

Preliminary Class

502

Correct to:

"High-temperature Denitration Catalysts  
and Processes for Preparing Same"

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